

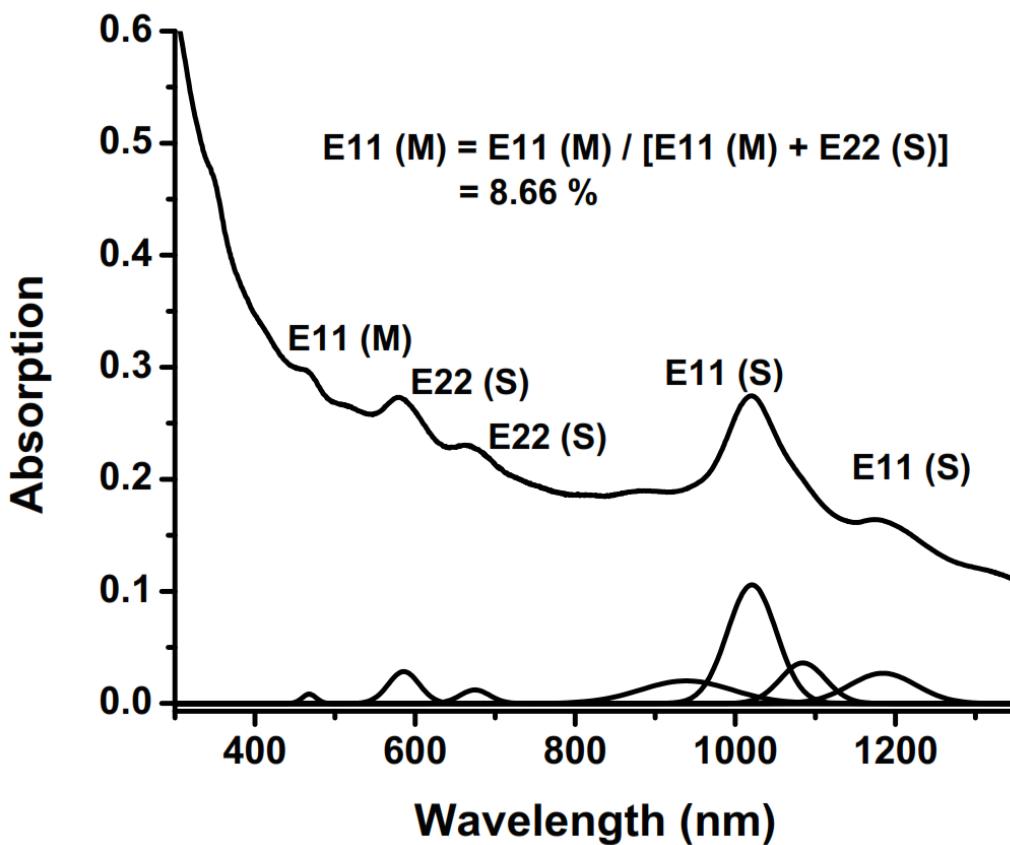
## Performance Dependence of SWCNT/n-Silicon Hybrid Solar Cells on the Charge Carrier Concentration in Silicon Substrates

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**Figure S1.** Optical absorption spectrum of SWCNT dispersion before SWCNT film fabrication. The peaks were fitted (Adjusted  $R^2 - 0.999108$ ) in order to determine the different SWCNT species present. After integrating the area under the fitted peaks, the metallic contents in the dispersion was found to be ~8.66%.<sup>1,2,3</sup>

**Table S1.** Table summarizing the open-circuit voltages ( $V_{oc}$ ), short-circuit current densities ( $J_{sc}$ ), fill factor (FF), power conversion efficiencies, series resistance ( $R_s$ ) and shunt resistance ( $R_{sh}$ ) obtained from the solar cell devices.

	Si-1	Si-2	Si-3	Si-4	Si-5	Si-6
<b><math>V_{oc}</math> (V)</b>	0	0.008±0.0003	0.405±0.001	0.295±0.003	0.297±0.003	0.059±0.003
<b><math>J_{sc}</math> (mA/cm<sup>2</sup>)</b>	0	8.52±0.50	10.18±0.19	13.19±0.15	14.90±0.4	0.29±0.01
<b>FF</b>	0	0.26±0.05	0.57±0.01	0.4±0.01	0.33±0.01	0.24±0.01
<b>Efficiency (%)</b>	0	0.02±0.01	2.35±0.02	1.57±0.04	1.43±0.07	0.004±0.001
<b><math>R_s</math> (kΩ)</b>	0	0.009±0.002	0.115±0.001	0.144±0.005	0.159±0.007	2.91±0.16
<b><math>R_{sh}</math> (kΩ)</b>	0	0.010±0.001	15.7±1.8	1.18±0.16	0.62±0.10	2.93±0.13

## References

- 1 M.S. Arnold, A.A. Green, J.F. Hulvat, S.I. Stupp, M.C. Hersam, *Nature Nanotechnology*, 2006, **1**, 60 – 65.
- 2 F. Bonaccorso, T. Hasan, P.H. Tan, C. Sciascia, G. Privitera, G. Di Marco, P.G. Gucciardi, A.C. Ferrari, *J. Phys. Chem. C*, 2010, **114**, 17267–17285.
- 3 H. Huang, H. Kajiura, R. Maruyama, K. Kadono, K. Noda, *J. Phys. Chem. B*, 2006, **110**, 4686–4690.